





Science and Technology **Facilities Council** 

### Ultra-pure Copper Electroforming for Background Suppression in **Rare-Event Searches**

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## Copper as a Construction Material

- Copper is common material for rare event searches Strong enough to build limited-pressure vessels or support structures
  - Commercially available at high purity
  - •Low cost
  - No long-lived radio-isotopes
    - Longest is  ${}^{67}Cu$ ,  $t_{1/2}$ = 62 hours









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Long-lived <sup>238</sup>U daughters introduced by <sup>222</sup>Rn gas







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## **Electrolytic Cell and Electroplating**

- Electrolysis governed by oxidation and reduction reactions
  - •Reduction of ions requires supply of electrons  $\rightarrow$  Current
  - •Also requires energy  $\rightarrow$  Potential difference
- Electroforming: lons gain electrons and deposit as atoms (reduction) at cathode  $\rightarrow$  material build-up
  - Supplied current drives reaction
  - Deposited mass proportional to current:

$$M = \frac{m_r \int I(t) \mathrm{d}t}{zF}$$





- M mass deposited
- m, molar mass
- I(t) current
- z number of electrons transferred
- F Faraday Constant(=  $eN_A$ )

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## **Purification Through Electroplating**

- Some ions reduce more readily than others Reduction potentials
- Copper benefits from 'electrowinning' high reduction potential +0.34 V
- Contaminants have lower reduction potential than copper
  - Copper refined during electroforming if electrode potential is low enough

Reductants		Oxidants	$E^0$ (
$Cu^{2+} + 2e^{-}$	<u> </u>	Cu	+0.3
$Pb^{2+} + 2e^{-}$		Pb	-0.1
$U^{3+} + 3e^{-}$		U	-1.8
$Th^{4+} + 4e^{-}$		$\mathrm{Th}$	-1.9
$K^+ + e^-$		Κ	-2.9



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## **Copper Purification**

Reaction that proceeds determined by standard cell potential:

$$E^0_{cell} = E^0_C - E^0_A$$

Related to change in Gibbs Free Energy:

$$\Delta G^0 = -zFE^0_{cell}$$

If  $\Delta G^0 < 0$ , then reaction is spontaneous If  $\Delta G^0 > 0$ , then extra energy is needed



 $E_C^0$  - standard reduction potential at cathode

 $E^0_A$  - standard reduction potential at anode



### **Example** of electrolyte containing U<sup>3+</sup> and Cu<sup>2+</sup> ions, with a Cu anode:

- To reduce  $U^{3+}$  to U:
  - $E^{0}_{cell}$  = -2.14 V  $\rightarrow$  Requires energy
- To reduce Cu<sup>2+</sup> to Cu
  - • $E^{0}_{cell} = 0 V \rightarrow In equilibrium$
- Cu<sup>2+</sup> reduction is energetically favourable to U<sup>3+</sup> reduction
- Potential difference required to drive reaction and overcome energy losses



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## Radiopurity of Electroformed Copper

- Current <sup>238</sup>U and <sup>232</sup>Th contaminations below sensitivity of most sensitive assay technique - ICP-MS
  - Bounds are just upper limit value may be much lower
- <sup>210</sup>Pb assayed with XIA UltraLo-1800  $\alpha$ -particle counter
- Again, below sensitivity of device



XIA UltraLo-1800 https://www.xia.com/ultralo-theory.html





### **ICP-MS** Assay

Copper Type	<sup>232</sup> Th [ppt] ( <i>µBq/kg</i> )	<sup>238</sup> U [ppt] ( <i>µBq/kg</i> )	Source
C10100	0.46±0.06 ( <i>1.19</i> ±0.25)	0.21±0.06 ( <i>2.54</i> ±0.74)	Majorana Demonstrator, (PNNL) 10.1016/j.nima.2016.04.0
Electroformed	<0.029 (<0.11)	<0.008 ( <i>&lt;0.10</i> )	Majorana Demonstrator, (PNNL) 10.1016/j.nima.2016.04.0
Electroformed	0.035±0.004 ( <i>0.14</i> )	<0.050 (<0.06)	CES, LSC 10.1063/1.5018987

### XIA UltraLo-1800 Assay

Sample	<sup>210</sup> Pb contamination	<sup>210</sup> Po conta
-	(mBq/kg)	(mBg
OFC#1 (C1020) (MMC)	40±8	47±
OFC#2 (C1020) (MMC)	20±6	33±
OFC#3 (C1020) (MMC)	27±7	(1.6±0.3
OFC#4 (C1020) (MMC)	23±8	(2.2±0.4
OFC#5 (C1020) (SH copper products)	17±6	44±
OFC#6 (C1020) (SH copper products)	27±8	24±
OFC (class1) (SH copper products)	36±13	38±
Coarse copper (MMC)	(57±1)×10 <sup>3</sup>	(16±2)
Bare copper (MMC)	8.4±4.0	(1.1±0.2
OFC (MMC)	23±8	(1.3±0.3
6N copper (MMC)	<4.1	<4
Electroformed copper (Asahi-Kinzoku)	<5.3	<1
	NIMA 884 (2018) 157 161	

<u>INIIVIA 004 (2010) 157-101</u>

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### 16/11/2021





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## PureAlloys

- Copper has drawback of low strength and high ductility
- Alloys generally used to improve mechanical properties
- Recent exploration of ultra-pure Cu-Cr layered alloys at PNNL
  - Alternately deposit Cu and Cr, and heat to alloy
  - Benefit from improved strength
  - Work ongoing to identify minimum Cr to keep radioisotopes low
  - 50% increase in hardness with 1% (w/w) Cr
- Would allow less material to be used, speeding up process
- Birmingham exploring collaboration with material scientists to study and model the processes



### Cr electroplated on EFCu



NIMA 1003 (2021) 165291

16/11/2021

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## Use by Rare Event Searches

Ultra-pure copper electroforming already used by several experiments Majorana Demonstratoe NIMA 828 (2016) 22-36 •NEWS-G <u>NIMA 988 (2021) 164844</u> •ANAIS Eur.Phys.J.C 79 (2019) 3, 228 Mentioned as a prerequisite for future experiments nEXO <u>1805.11142</u> JINST 13 (2018) 12, P12010 NEXT •LEGEND <u>1905.06572</u>

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MAJORANA Demonstrator, Cryostat IR Shield

https://www.npl.washington.edu/ majorana/majorana-experiment





NIMA 988 (2021) 164844

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## Deep Underground Electroformed Copper

- Electroforming underground suppresses background contribution from cosmogenic activation
- Already demonstrated feasibility by NEWS-G collaboration
  - •500 µm layer plated to inner surface of 140 cm detector
  - Plating rate ~1 mm/month



Contents lists available at ScienceDirect



Nuclear Inst. and Methods in Physics Research, A

journal homepage: www.elsevier.com/jocate/nima

Copper electroplating for background suppression in the NEWS-G experiment L. Balogh\*, C. Beaufort<sup>b</sup>, A. Brossard\*, R. Bunker<sup>e</sup>, J.-F. Caron<sup>\*</sup>, M. Chapellier\*,

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### NIMA 988 (2021) 164844

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	Weight	<sup>232</sup> Th	$^{238}\mathrm{U}$
Sample	[g]	$[\mu Bq/kg]$	$[\mu Bq/$
C10100 Cu (Machined)	-	$8.7\pm1.6$	$27.9 \pm$
Cu Electroformed	-	< 0.119	< 0.09
Hemisphere 1	0.256	< 0.58	< 0.26
Hemisphere 2	0.614	< 0.24	< 0.11





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## ECuME in SNOLAB

- 1.4 m diameter SPC electroforming ~2 m diam electroforming bath
- Largest underground ultra-pure Cu electroforming facility
- Leadership from PNNL, and input from SNOLAB, Queen's U. (Canada), Birmingham
- Strong Birmingham involvement in project, and in previous electroplating
- Initially dedicated for an SPC, then will be available for users

### Status:

- R&D for 30 cm prototype bath at PNNL
  - Procurement of parts underway
- Prototype to begin electroforming soon
- Full-scale planned to be underway early 2022
- Physic exploitation will follow SNOGLOBE

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### n electroforming bath ing facility B, Queen's U. (Canada), Birmingham I in previous electroplating able for users



### Prototype for NEWS-G Electroforming



## Electroforming in Boulby

- STFC awarded funding for 'scope, feasibility and costing' study of establishing an electroplating facility in Boulby
  - What is the cost of set-up and maintenance?
  - Can it feasibly be established in Boulby?
  - Scope: Are future/current experiments interested in the capability?
- Survey ongoing to assess UK interest in facility
  - Circulated to DM-UK community and in HiPhi newsletter
  - Second survey being opened to international community
- Facility would complement BUGS, especially the XIA UltraLo-1800

### Ultra-Pure Copper Electroforming Capability in the UK

Rare event search experiments have been pushing the frontiers of low radioactivity for decades in the pursuit of new physics. One major development in recent years is the use of high-radiopurity electroformed copper, which suppresses typical contaminants including those from the U238/Th232 and Rn222 decay chains. More recently, underground electroforming is being undertaken to also suppress cosmogenic activation. In particular, the underground laboratories of Modane, Canfranc and Snolab are exploring electroforming. The ECuME project, funded in Canada, will establish a large-scale deep underground electroforming facility in Snolab.

This survey is to gauge the relevance for the UK rare-event search community of an underground electroforming facility at the Boulby Underground Laboratory.





Costing and feasibility: ECuME expertience

### https://www.surveymonkey.co.uk/r/7JLT2DW

The survey is still open, if you would like to provide input (<2 mins to complete)







## Summary

- Copper has desirable qualities as detector material High reduction potential allows copper to be purified in electroforming process
  - Unparalleled radiopurity achieved through this process Purity below sensitivity of world-leading assay techniques
- Electroforming underground suppresses cosmogenic activation
- Several underground laboratories exploring technology
- Explored by future experiments
- ECuME will be the deepest and largest electroforming capability in the world!
  - •UK has unique opportunity to capitalise on this investment!





